



Features

- Drain-Source Breakdown Voltage V_{DSS} 20 V
- Drain-Source On-Resistance
 - $R_{DS(ON)}$ 17mΩ, at V_{GS} = 4.5V, I_{DS} = 6.4A
 - $R_{DS(ON)}$ 20mΩ, at V_{GS} = 2.5V, I_{DS} = 5.5A
 - $R_{DS(ON)}$ 25mΩ, at V_{GS} = 1.8V, I_{DS} = 5.0A
- Continuous Drain Current at $T_A=25^\circ\text{C}$ I_D = 6.4A
- Advanced high cell density Trench Technology
- RoHS Compliance & Halogen Free
- ESD protection

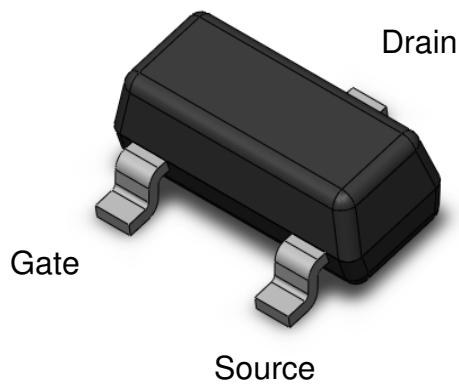
Applications

- Power Management
- Battery Powered System
- Portable Equipment
- DC/DC Converter

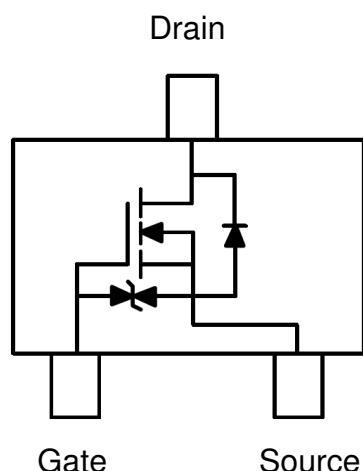
Description

The CTL0642NS-R3 is the N-Channel logic enhancement mode power field effect transistors are produced using high cell density, DMOS trench technology. This high density process is especially tailored to minimize on-state resistance.

Package Outline



Schematic





CTL0642NS-R3

N-Channel Enhancement MOSFET

Absolute Maximum Rating at 25°C

Symbol	Parameters	Ratings	Units	Notes
V_{DS}	Drain-Source Voltage	20	V	
V_{GS}	Gate-Source Voltage	± 8	V	
I_D	Continuous Drain Current @ $T_A=25^\circ\text{C}$	6.4	A	1
I_{DM}	Pulsed Drain Current	30	A	1
P_D	Total Power Dissipation @ $T_A=25^\circ\text{C}$	1.4	W	2
T_{STG}	Storage Temperature Range	-55 to 150	°C	
T_J	Operating Junction Temperature Range	-55 to 150	°C	

Thermal Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
$R_{\Theta JA}$	Thermal Resistance Junction-Ambient ($t=10\text{s}$)		-	75	-	°C /W	1,4



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Electrical Characteristics $T_A = 25^\circ\text{C}$ (unless otherwise specified)

Static Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
B_{VDSS}	Drain-Source Breakdown Voltage	$V_{GS}=0V, I_D= 250\mu\text{A}$	20	-	-	V	
I_{DSS}	Drain-Source Leakage Current	$V_{DS} = 20\text{V}, V_{GS} = 0\text{V}$	-	-	1	μA	
I_{GSS}	Gate-Source Leakage Current	$V_{GS} = \pm 8\text{V}, V_{DS} = 0\text{V}$	-	-	± 10	μA	

On Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
$R_{DS(ON)}$	Drain-Source On-Resistance	$V_{GS} = 10\text{V}, I_D = 6.4\text{A}$	-	17	21	$\text{m}\Omega$	3
		$V_{GS} = 10\text{V}, I_D = 5.5\text{A}$		20	25	$\text{m}\Omega$	
		$V_{GS} = 4.5\text{V}, I_D = 5.0\text{A}$	-	25	33	$\text{m}\Omega$	
$V_{GS(\text{TH})}$	Gate-Source Threshold Voltage	$V_{GS} = V_{DS}, I_D = 250\mu\text{A}$	0.4	0.6	1.0	V	3

Dynamic Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
C_{iss}	Input Capacitance	$V_{DS} = 10\text{V}, V_{GS} = 0\text{V}, f = 1\text{MHz}$	-	150	-	pF	
C_{oss}	Output Capacitance		-	95	-		
C_{rss}	Reverse Transfer Capacitance		-	25	-		

Switching Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
$T_{D(ON)}$	Turn-On Delay Time	$V_{DS} = 10\text{V}, V_{GS} = 5\text{V}, R_G = 3\Omega, R_L = 1.5\Omega$	-	250	300	ns	
T_R	Rise Time		-	420	500		
$T_{D(OFF)}$	Turn-Off Delay Time		-	3950	4200		
T_F	Fall Time		-	3700	3900		
Q_G	Total Gate Charge	$V_{DS} = 10\text{V}, V_{GS} = 4.5\text{V}, I_D = 6.5\text{A}$	-	10	12	nC	
Q_{GS}	Gate-Source Charge		-	0.9	-		
Q_{GD}	Gate-Drain (Miller) Charge		-	3	-		



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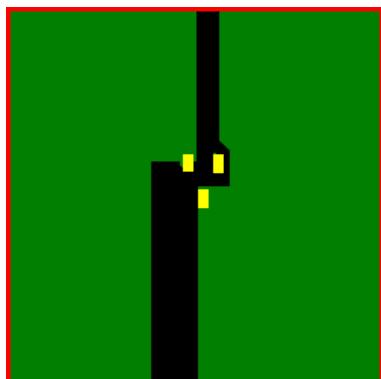
N-Channel Enhancement MOSFET

Drain-Source Diode Characteristics

Symbol	Parameters	Test Conditions	Min	Typ	Max	Units	Notes
V_{SD}	Body Diode Forward Voltage	$V_{GS} = 0V$, $I_D = 1A$		0.6	1	V	
I_{SD}	Body Diode Continuous Current				1	A	1

Note:

1. The power dissipation is limited by 150°C junction temperature.
2. Device mounted on a glass-epoxy board



Actual Size

3. The data tested by pulsed , pulse width $\leq 300\mu s$, duty cycle $\leq 2\%$
4. Thermal Resistance follow JESD51-3.



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Typical Characteristic Curves

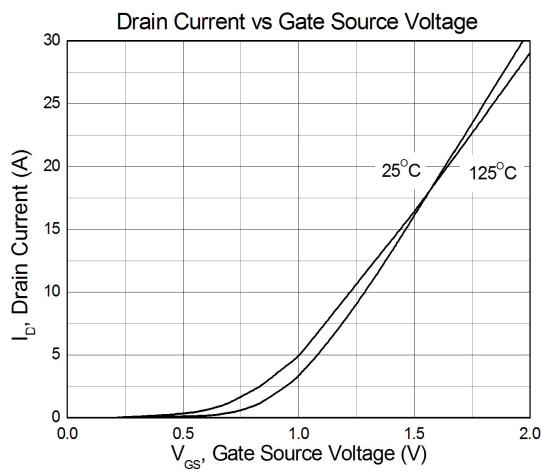


Figure 1

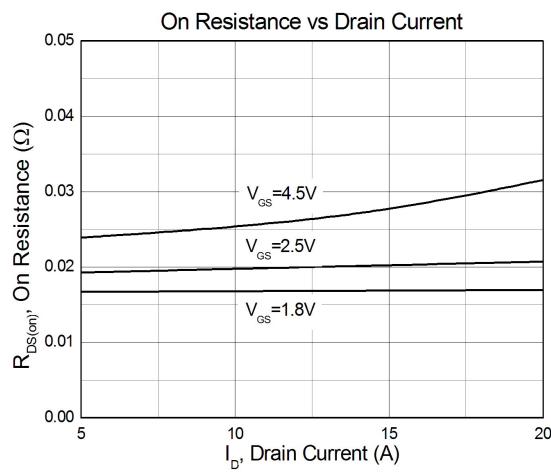


Figure 2

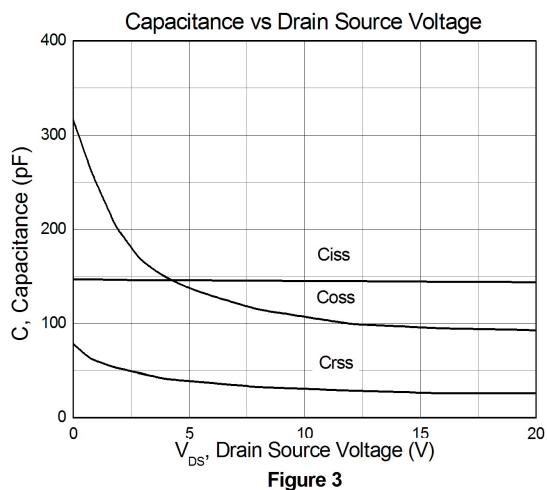


Figure 3

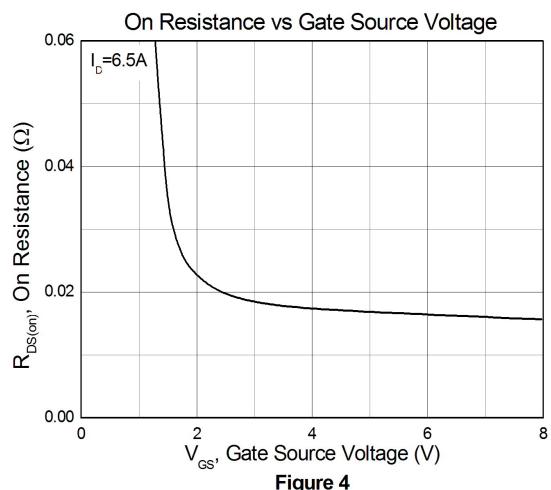


Figure 4

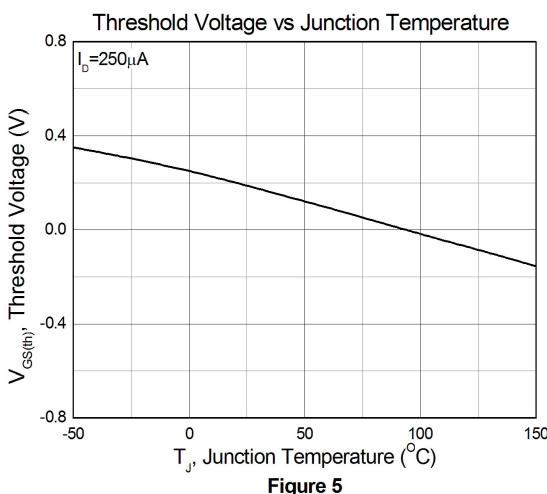


Figure 5

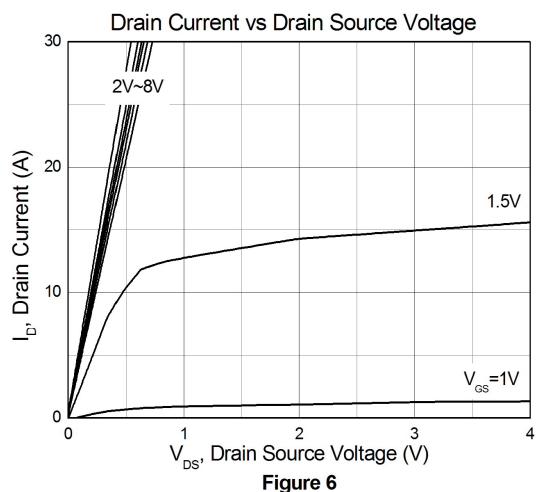


Figure 6



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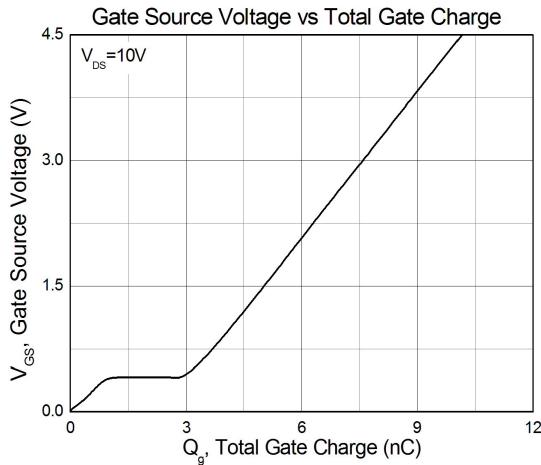


Figure 7

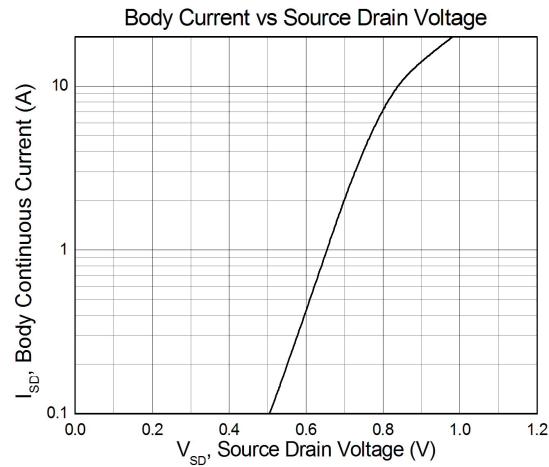


Figure 8



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Test Circuits & Waveforms

Figure 9: Gate Charge Test Circuit

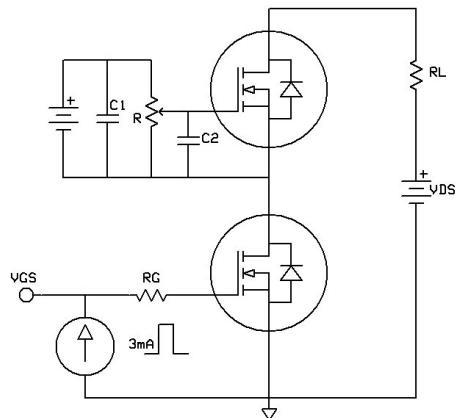


Figure 10: Gate Charge Waveform

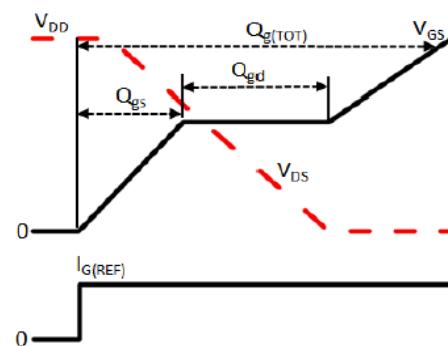


Figure 11: Switching Time Test Circuit

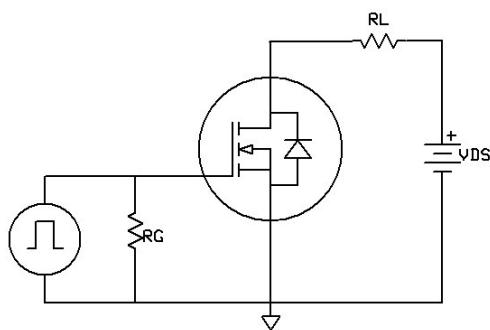
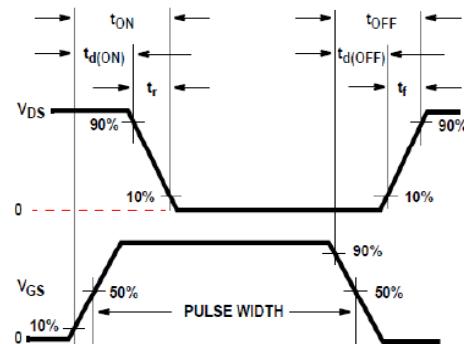


Figure 12: Switching Time Waveform

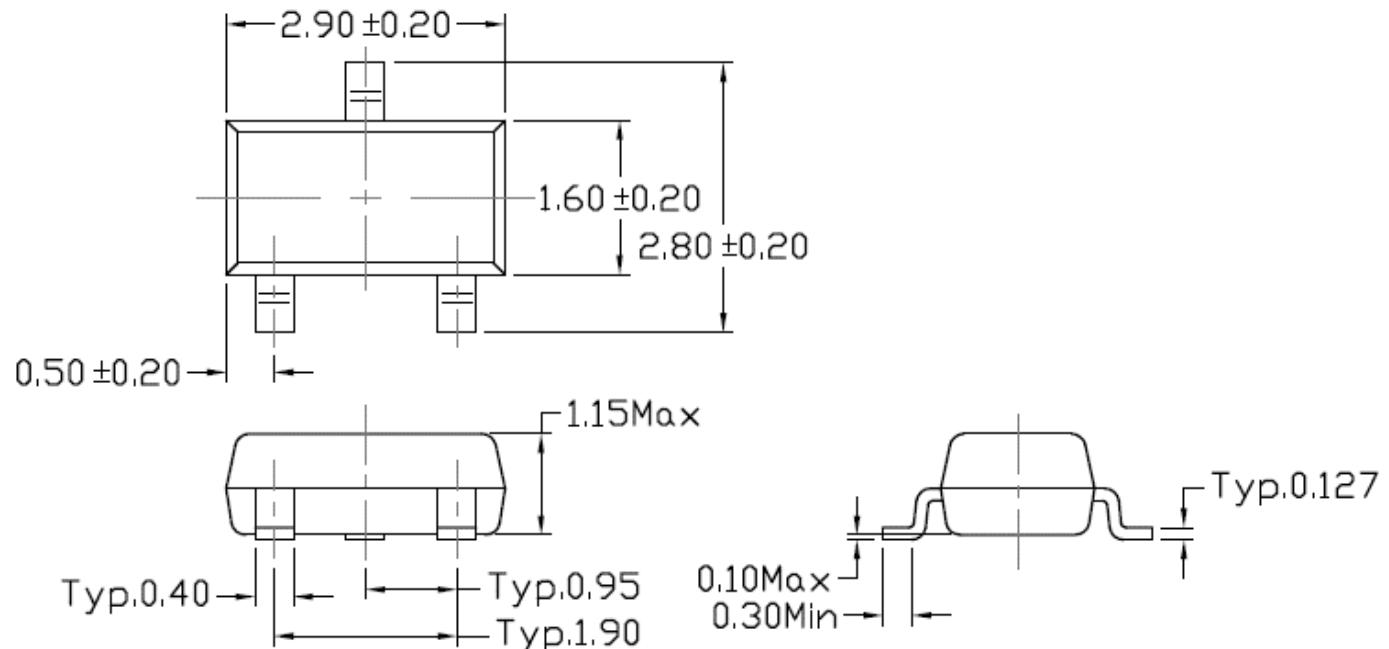




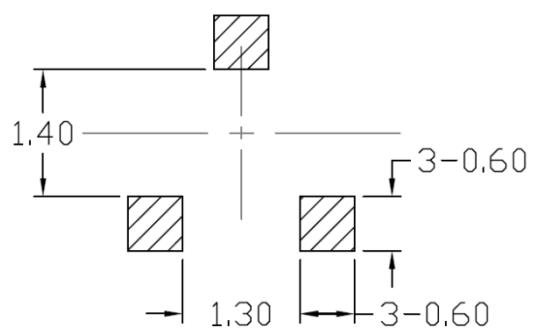
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Package Dimension (SC-59)



Recommended pad layout for surface mount leadform

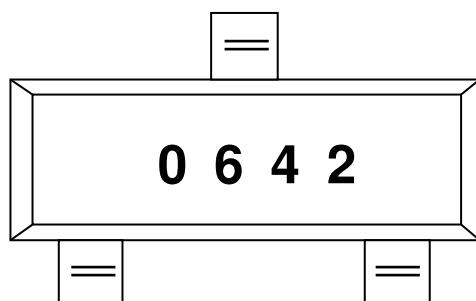




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Marking Information



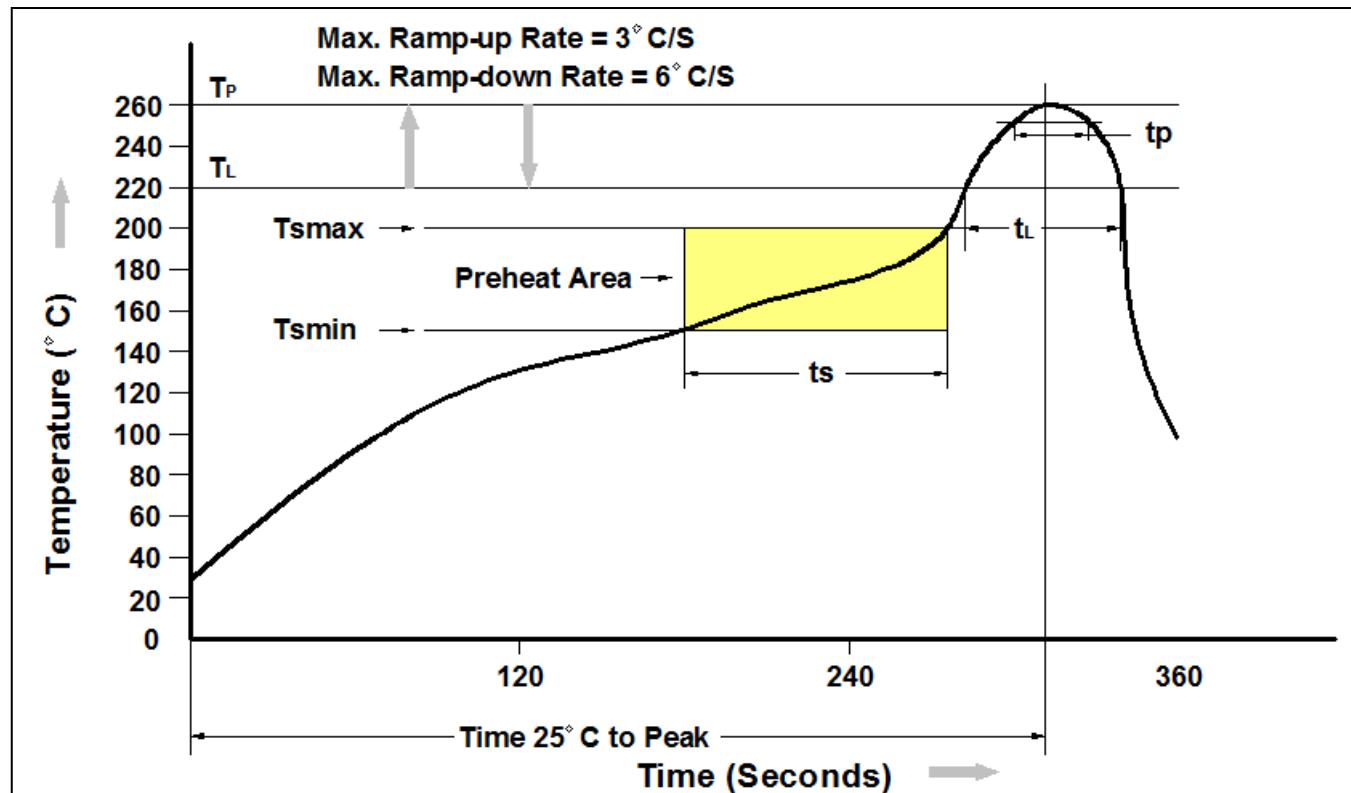
0642 : Device Number

Ordering Information

<i>Part Number</i>	<i>Description</i>	<i>Quantity</i>
CTL0642NS-R3	SC-59 Reel	3000 pcs



Reflow Profile



Profile Feature	Pb-Free Assembly Profile
Temperature Min. (T _{smin})	150°C
Temperature Max. (T _{smax})	200°C
Time (t _s) from (T _{smin} to T _{smax})	60-120 seconds
Ramp-up Rate (t _L to t _P)	3°C/second max.
Liquidous Temperature (T _L)	217°C
Time (t _L) Maintained Above (T _L)	60 – 150 seconds
Peak Body Package Temperature	260°C +0°C / -5°C
Time (t _p) within 5°C of 260°C	30 seconds
Ramp-down Rate (T _P to T _L)	6°C/second max
Time 25°C to Peak Temperature	8 minutes max.



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